

AZ5214 (positive mode)

Tone	Positive
Reference	http://www.microchemicals.com/products/photoresists/az_5214e.html
Spincoat	primer HMDS: 3000rpm, bake on hotplate 200°C for 2 minutes AZ5214: 2000rpm 1.98µm, 3000rpm 1.62µm, 4000rpm 1.4µm, 5000rpm 1.25µm, 6000rpm 1.14µm,
Bake	in oven at 90°C for 15 minutes
Exposure	DMO_ML2: 80 mJ/cm ² @405nm wavelength HBG_uMLA: 250 mJ/cm ² (pneumatic focussing, defoc -4)
Development	MF321 for 60s
Rinse	water